Abstract No. P21TS07_1386



Interface engineering for improving the performance of metal halide perovskite photodiode

Seung Chan Yoo, Kyu Young Kim, Young Woong Kim, Jun Kyu Choi, and Young Jin Choi*

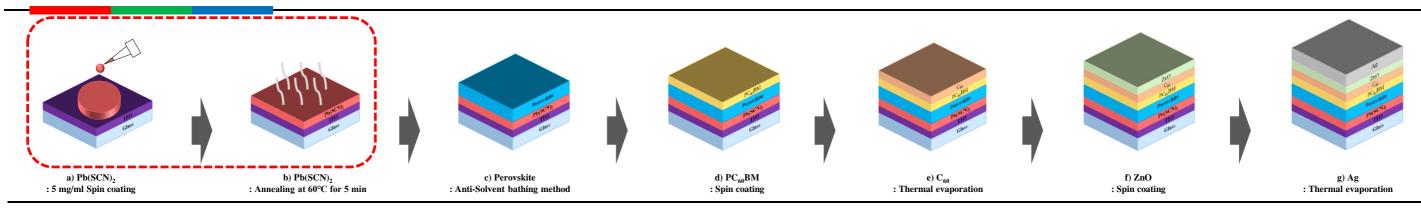
Department of Nanotechnology and Advanced Materials Engineering, Sejong University, Seoul, 05006, Republic of Korea Fax: +82-(2)-3408-4342 E-mail address: jini38@sejong.ac.kr

Introduction

Metal halide perovskite has emerged as a next-generation candidate for the active layer of photodiodes by replacing silicon due to its excellent optoelectronic properties such as high absorption coefficient, long carrier lifetime and light absorption selectivity. Perovskite can absorb light selectively because their band gap can be tuned by changing the composition of halide at the X site. However, it is still challenging to synthesize metal halide perovskites absorbing blue light.

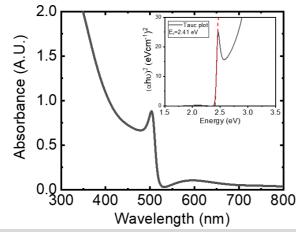
It is well known that the ratio of chlorine (Cl) in X site should be increased to absorb light in the short wavelength (400 nm ~ 520 nm) region and lead acetate (Pb(CH₃COO)₂) has been widely used in the synthesis process because of its low solubility of Cl. However, lead acetate accelerates the nucleation of perovskite and reduces the grain size, which makes it difficult to improve perovskite photodiodes (PePDs) performance. To enlarge the grain size of the perovskite, some methods, such as solvent engineering, interface engineering, and incorporating additives into the perovskite film have been reported. In this study, we inserted the Pb(SCN)₂ layer into the interface between ITO and perovskite to increase the grain size of the perovskite, and we report its effects on the properties of PePDs as a function of the thickness of the Pb(SCN)₂ layer.





Result & Discussion

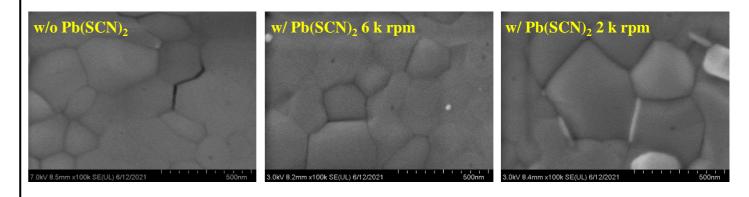
- Absorption spectra of the perovskite



 \cdot We synthesized MA_{0.6}FA_{0.4}PbBr_{2.4}Cl_{0.6} perovskite film.

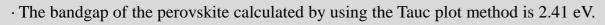
 \cdot The absorption onset of perovskite was 528 nm and the absorption peak was located at 503 nm

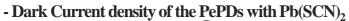
- FE-SEM image of perovskite film

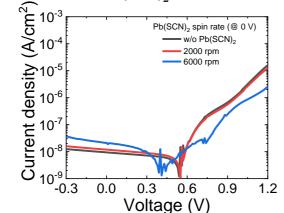


 \cdot The thickness of Pb(SCN)₂ was controlled by varying the spin coating speed.

 \cdot The grain size of the perovskite film without Pb(SCN)₂ and the perovskite film with thin

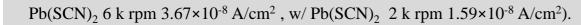


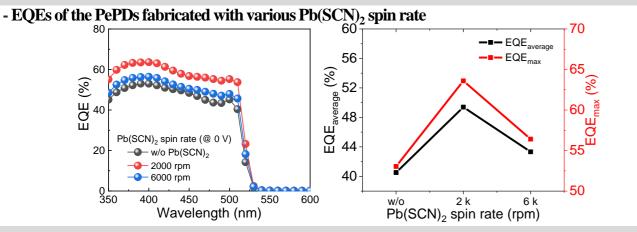




 \cdot The devices show low dark current density regardless of Pb(SCN)₂ thickness.

. The dark current density is almost identical at -0.3 V. (w/o Pb(SCN)₂ 1.44×10^{-8} A/cm², w/

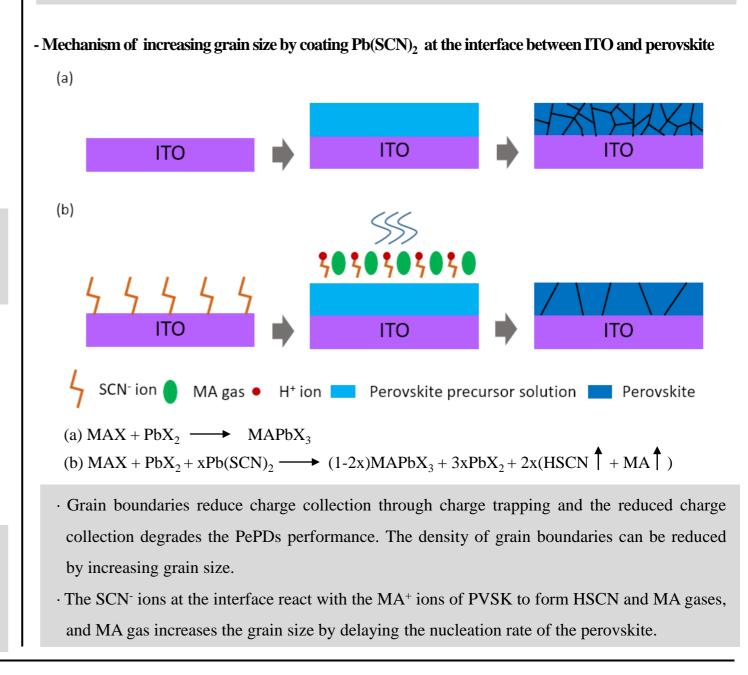




The EQE of the PePD without Pb(SCN)₂ film and the PePD with thin Pb(SCN)₂ film(6 k rpm) was almost identical, but that of the PePD with thick Pb(SCN)₂ film(2 k rpm) was enhanced.
The maximum EQE increased from 53.0 % to 63.6 % and the averaged EQE increased from 40.5 % to

49.4% by incorporating $Pb(SCN)_2$ film formed with a spin rate of 2 k rpm.

 $Pb(SCN)_2$ film(spin coating speed : 6 k rpm) was almost identical, but it was enlarged in the perovskite film with thick $Pb(SCN)_2$ film(spin coating speed : 2 k rpm).



Conclusion

- The grain size of perovskite was increased by forming Pb(SCN)₂ at the interface between ITO and perovskite.
- EQE of the PePD increased when Pb(SCN)₂ was coated at the interface. However, because sufficient Pb(SCN)₂ is required for the SCN⁻ and MA⁺ ions to react at the interface, it is necessary to coat Pb(SCN)₂ layer over critical thickness.
- These results would be expected in the red or green perovsktie photodiode as well.

Acknowledgement

• This research was supported by Creative Materials Discovery Program through the National Research Foundation of Korea(NRF) funded by Ministry of Science and ICT(2019M3D1A2104109).



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